

Amendments to the Abstract:

ABSTRACT

~~The invention concerns a~~ A measuring device for process technology, useful in measuring- and/or cleaning- and/or calibration-installations in the field of process automation for measuring pH-values and/or redox potentials and/or other process parameters, and an operating method therefor. The measuring device includes at least one central unit having at least one central computer $[(1)]$, wherein, in the central computer $[(1)]$ a management system $[(4)]$ is provided for the dynamic management of input components (I) and/or output components (O) and/or functional components (F) and/or service components (D) and/or management components (V) and/or interface components (IX) and/or other system components.

$[(Fig. 1)]$